# Chemical Science



### **EDGE ARTICLE**

View Article Online
View Journal | View Issue



Cite this: Chem. Sci., 2020, 11, 276

d All publication charges for this article have been paid for by the Royal Society of Chemistry

Received 6th October 2019 Accepted 9th November 2019

DOI: 10.1039/c9sc05018c

rsc.li/chemical-science

# Controllable double CF<sub>2</sub>-insertion into sp<sup>2</sup> C-Cu bond using TMSCF<sub>3</sub>: a facile access to tetrafluoroethylene-bridged structures†

Qiqiang Xie, Ziyue Zhu, Lingchun Li, Chuanfa Ni and Jinbo Hu 🕒 \*

A highly efficient method for controllable double  $CF_2$ -insertion into pentafluorophenylcopper species using  $TMSCF_3$  as difluoromethylene source has been developed. The newly generated fluoroalkylcopper(I) species,  $C_6F_5CF_2CF_2Cu$ , shows good reactivity towards a myriad of structurally diverse aryl, heteroaryl and alkenyl iodides. This protocol is easy to handle, ready to scale up and applicable for the synthesis of relative complex molecules, thus providing a convenient method for facile access to tetrafluoroethylene-bridged structures.

#### Introduction

Due to the unique physical, chemical and biological properties of organofluorine compounds, the introduction of fluorine atom(s) or fluorinated moieties into organic molecules has become a routine strategy in drug design and advanced material development. Among various fluorinated functionalities, the tetrafluoroethylene motif (-CF<sub>2</sub>CF<sub>2</sub>-) has attracted considerable attention because of its applications in agrochemicals and liquid-crystalline materials. Moreover, the introduction of -CF<sub>2</sub>CF<sub>2</sub>- group into liquid crystals often results in highly advantageous properties such as high clearing temperature, broad nematic phase range, low rotational viscosity and high dielectric anisotropy. Therefore, it is of strong demand to access tetrafluoroethylene-bridged molecules.

Current methods for the syntheses of tetrafluoroethylene-bridged structures are mainly based on (1) deoxofluorination of 1,2-dicarbonyl compounds with SF<sub>4</sub> and DeoxoFluor;<sup>9-11</sup> (2) fluorination of C-C triple bonds using F<sub>2</sub>;<sup>12-14</sup> (3) 1,2-difunctionalization of tetrafluoroethylene (TFE);<sup>15-23</sup> (4) difluoromethylene insertion using CF<sub>2</sub>Br<sub>2</sub> as the CF<sub>2</sub> source;<sup>24,25</sup> and (5) using RCF<sub>2</sub>CF<sub>2</sub>Br as the build block.<sup>5</sup> However, these methods suffer from several drawbacks such as (1) using toxic, highly reactive or hazardous reagents; (2) low functional group tolerance and/or (3) using explosive gaseous reagents or ozone-depleting substances (ODS). As such, developing a new method to incorporate -CF<sub>2</sub>CF<sub>2</sub>- structure motif into organic

molecules with readily available, easy to handle and environmentally benign reagents under mild conditions is highly desired.

(Trifluoromethyl)trimethylsilane (TMSCF<sub>3</sub>), often called Ruppet-Prakash reagent, is arguably the most widely used trifluoromethylating agent.26-30 In 2011, our group, in collaboration with the Prakash group, revealed that TMSCF3 is a good difluorocarbene precursor, which can be used in the [2] + 1] cycloaddition reaction with alkenes and alkynes.31 Recently, our group reported that difluorocarbene generated from TMSCF3 could undergo dimerization to give tetrafluoroethene (TFE),32,33 which can be used for a variety of transformations.33 Very recently, our group demonstrated that, by using TMSCF<sub>3</sub> as the difluoromethylene source, controllable CF2-insertion into CuCF3 to generate CuCF2CF3 could be realized.34 Inspired by this C<sub>1</sub> to C<sub>2</sub> process, we envisioned that it might be possible to insert CF2 into other C-M bonds. Herein, we report our latest progress in the fluorocarbon homologation reaction using TMSCF<sub>3</sub> as the difluoromethylene source. By carefully tuning the reaction conditions, controllable double insertion of CF2 into C6F5-Cu gives rise to C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu, which can be applied to the preparation of a diverse range of tetrafluoroethylene-bridged compounds (Scheme 1).

Scheme 1 Fluorocarbon homologation with  $TMSCF_3$ . TMS = trimethylsilyl.

Key Laboratory of Organofluorine Chemistry, Center for Excellence in Molecular Synthesis, Shanghai Institute of Organic Chemistry, University of Chinese Academy of Sciences, Chinese Academy of Sciences, 345 Lingling Road, Shanghai 200032, China. E-mail: jinbohu@sioc.ac.cn

<sup>†</sup> Electronic supplementary information (ESI) available. CCDC 1957757. For ESI and crystallographic data in CIF or other electronic format see DOI: 10.1039/c9sc05018c

a) Previous work: single  $CF_2$  insertion into  $CF_3Cu$  with  $TMSCF_3$   $CuCl + KF + TMSCF_3 \longrightarrow CuCF_2CF_3$ b) **This work**: double  $CF_2$  insertion into  $C_6F_5Cu$  with  $TMSCF_3$   $CuCl + KF + TMSC_6F_5 \longrightarrow CuC_6F_5 \xrightarrow{TMSCF_3} CuCF_2CF_2C_6F_5$ 

#### Results and discussion

**Edge Article** 

Our investigation commenced with the preparation of C<sub>6</sub>F<sub>5</sub>-CF<sub>2</sub>CF<sub>2</sub>Cu from TMSC<sub>6</sub>F<sub>5</sub> and TMSCF<sub>3</sub>. Initially, we used 1 equivalent of TMSC<sub>6</sub>F<sub>5</sub> as the C<sub>6</sub>F<sub>5</sub>Cu precursor, 1 equivalent of TMSCF<sub>3</sub> as the difluorocarbene precursor, 2 equivalents of KF as the desilylating reagent and 2.5 equivalents of CuCl as the copper source. All these components were added simultaneously with DMF as the solvent, and the resulting mixture was stirred at room temperature for 12 hours. Analysis of the mixture by <sup>19</sup>F NMR spectroscopy revealed that C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu (21%), C<sub>6</sub>F<sub>5</sub>Cu (57%) and CuCF<sub>3</sub> (37%) were formed; no single CF<sub>2</sub>-insertion product C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>Cu could be detected (Table 1, entry 1). When adding 2 equivalents of difluorocarbene source TMSCF<sub>3</sub>, we found that the desired product C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu was formed in 79% yield, in conjunction with C<sub>6</sub>F<sub>5</sub>Cu (3%), CuCF<sub>3</sub> (10%) and CuC<sub>2</sub>F<sub>5</sub> (5%) (entry 2).35 If 3 equivalents of TMSCF<sub>3</sub> was used, C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu was formed in 83% yield, along with CuCF<sub>3</sub> (16%) and CuC<sub>2</sub>F<sub>5</sub> (12%) being formed; neither C<sub>6</sub>F<sub>5</sub>Cu nor triple CF<sub>2</sub>-insertion product C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>CF<sub>2</sub>Cu could be detected (entry 3). These results (entries 1-3) clearly indicate that the TMSCF<sub>3</sub>-derived difluorocoppercarbene (Cu=CF<sub>2</sub>) species34 could selectively undergo double CF2-insertion into C<sub>6</sub>F<sub>5</sub>Cu, regardless of the amount of TMSCF<sub>3</sub> used. This behaviour is in accord with previous reports.24 The high selectivity may be attributed to the intrinsic reactivity of different fluoroalkylcopper species toward Cu=CF<sub>2</sub> (Scheme 2). As to the possible intermediate, C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>Cu, its benzylic C-Cu bond is highly reactive and tended to insert another CF2 unit to give C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu;<sup>24,25</sup> the resulting C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu has lower reactivity than CuCF<sub>3</sub> because of its longer fluoroalkyl chain.<sup>24,25</sup> Therefore, even in the presence of excess of TMSCF<sub>3</sub>, triple CF<sub>2</sub>-

$$\begin{array}{c} \text{CuCF}_{3} \longrightarrow [\text{Cu=CF}_{2}] \xrightarrow{C_{6}F_{5}\text{Cu}} \xrightarrow{C_{6}F_{5}\text{CF}_{2}\text{Cu}} \xrightarrow{[\text{Cu=CF}_{2}]} \xrightarrow{C_{6}F_{5}\text{CF}_{2}\text{CF}_{2}\text{Cu}} \\ k_{1} \downarrow \text{CuCF}_{3} & k_{4} \downarrow [\text{Cu=CF}_{2}] \\ \text{CuC}_{2}F_{5} & \text{C}_{6}F_{5}\text{CF}_{2}\text{CF}_{2}\text{CC}_{2}\text{CC}_{2} \end{array}$$

Scheme 2 Proposed reaction mechanism

insertion into  $C_6F_5Cu$  could not be observed; in that case, the  $CF_2$ -insertion into  $CuCF_3$  to generate  $CuC_2F_5$  would be favoured. Altogether, the relative reaction rate of each step is  $k_3 > k_2 > k_1 > k_4$ .

With this understanding in mind, we went on to optimize the reaction conditions in order to increase the yield of C<sub>6</sub>F<sub>5</sub>-CF<sub>2</sub>CF<sub>2</sub>Cu and minimize those of CuCF<sub>3</sub> and CuC<sub>2</sub>F<sub>5</sub>. By using 2 equivalents of TMSCF3 and prolonging reaction time to 20 hours, C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu was formed in 87% yield (entry 4). When we decreased the amount of CuCl from 4 equivalents to 3 equivalents, only trace of C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu was observed, with >80% C<sub>6</sub>F<sub>5</sub>Cu and CuCF<sub>3</sub> being recovered (entry 5). This result revealed that the presence of excess amount of CuCl is crucial for the Cu=CF<sub>2</sub> generation, which is consistent with our previous report.34 As CuCF3 was always observed, we tried to speed up the decomposition of CuCF<sub>3</sub> at elevated temperatures. However, when the reaction was carried out at 50 °C, although no CuCF3 was observed, a larger amount of CuC2F5 was detected, and C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu was obtained in relatively lower yield (entry 6 vs. entry 4). Next, we attempted to add TMSCF<sub>3</sub> into the reaction mixture after the preparation of C<sub>6</sub>F<sub>5</sub>Cu. Gratifyingly, the yield of C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu was increased slightly (entry 7). In light of the decomposition of CuCF<sub>3</sub> to Cu=CF<sub>2</sub> would release

Table 1 Optimization of reaction conditions for the double  $CF_2$  insertion into  $C_6F_5Cu$  with TMSCF<sub>3</sub><sup>a</sup>

$$\mathsf{TMSC}_6\mathsf{F}_5 + \mathsf{CuCl} + \mathsf{KF} \xrightarrow{\qquad \qquad \mathsf{DMF} \qquad \qquad } \mathsf{C}_6\mathsf{F}_6\mathsf{Cu} \xrightarrow{\qquad \qquad \mathsf{TMSCF}_3 \qquad } \mathsf{C}_6\mathsf{F}_6\mathsf{CF}_2\mathsf{CF}_2\mathsf{Cu}$$

Entry	$TMSC_6F_5:CuCl:KF:TMSCF_3$	<i>t</i> (h)	T (°C)	Yield (%)	
				$C_6F_5C_2F_4Cu$	C <sub>6</sub> F <sub>5</sub> Cu/CuCF <sub>3</sub> /CuC <sub>2</sub> F <sub>5</sub>
$1^b$	1:2.5:2:1	12	rt	21	57/37/n.d.
$2^b$	1:4:3:2	12	rt	79	3/10/5
$3^b$	1:5.5:4:3	12	rt	83	n.d./16/12
$4^b$	1:4:3:2	20	rt	87	4/2/4
$5^b$	1:3:3:2	20	rt	1	87/82/n.d.
$6^b$	1:4:3:2	10	50	75	1/n.d./23
7	1:4:3:2	28	rt	91	<1/<1/4
8	1:4:2:2	28	rt	76	n.d./2/5
$9^c$	1:4:3:2	28	rt	91	n.d./6/2
$10^d$	1:4:3:2	28	rt	93	n.d./8/2
$11^e$	1:4:3:1.9	28	rt	92	2/4/2
$12^e$	1:4:3:1.9	36	rt	86	3/4/2
$13^{e,f}$	1:4:3:1.9	28	rt	89	n.d./1/2

<sup>&</sup>lt;sup>a</sup> Reactions were performed on 0.2 mmol  $TMSC_6F_5$  (1.0 equiv.) scale. Yields were determined by <sup>19</sup>F NMR spectroscopy using PhOCF<sub>3</sub> as an internal standard. n.d. = not detected. <sup>b</sup>  $TMSC_6F_5$  and  $TMSCF_3$  were added simultaneously without the pre-preparation of  $C_6F_5Cu$ . <sup>c</sup>  $TMSCF_3$  was added in three portions for every 4 hours. <sup>d</sup>  $TMSCF_3$  was added in three portions for every 6 hours. <sup>e</sup>  $TMSCF_3$  was added in two portions for every 6 hours. <sup>f</sup> After reacted at rt for 28 hours, the reaction mixture was stirred at 60 °C for another 2 hours.

(cc)

**Chemical Science** 

fluoride ions, we surmised that the amount of externally added KF could be reduced. However, lowering down KF to 2 equivalents gave inferior result (entry 8). To further decrease the yield

1) CuCl. KF. DMF. RT. 0.5 h C<sub>6</sub>F<sub>5</sub>TMS 2) TMSCF<sub>3</sub>, rt, 28 h, then 60 °C, 2 h C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu 70 °C, t<sup>a</sup> CF<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>5</sub> F<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>6</sub> NO. NO-2a. 68%. 6 h 2b. 87%, 20 h 2c. 81%. 20 h CF2CeFe CF<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>6</sub> 2f 92% 20 h 2e. 96%, 20 h 2d, 89%, 20 hb CF2CF2C6F5 %∖ 2g, 90%. 20 h 2h. 87%. 6 h 2i. 91%. 20 h **2j**, 92%, 20 h 2k, 81%, 27 h 21, 82%, 26 h CF<sub>2</sub>C<sub>6</sub>F<sub>4</sub> F<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>6</sub> F<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>5</sub> .CO<sub>2</sub>Me 2n, 78%, 27 h 2o, 83%, 33 h 2p. 85%, 41 h 2a 88% 20 h 2r. 75%, 41 h F2CF2C6F 2u, 83%. 41 h 2t, 83%, 33 h 2s, 83%, 41 h<sup>t</sup> F<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>5</sub> 2v. 84%, 26 h 2w. 72%. 20 h 2x, 70%, 20 h F2CF2C6F CF<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>5</sub> 2y, 60%, 41 h 2aa, 70%, 41 h<sup>o</sup> CO<sub>2</sub>Et 2ac, 75%, 41 h 2ad, 88%, 41 hb 2ab, 54%, 41 h<sup>o</sup> F<sub>2</sub>CF<sub>2</sub>C<sub>6</sub>F<sub>6</sub> CF2CaFa 2ae 96% 33 h 2af, 88%, 41 h<sup>o</sup>

Scheme 3 Perfluorophenylethylation of (hetero)aryl iodides with TMSCF<sub>3</sub>-derived C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu. <sup>a</sup> Unless otherwise noted, reactions were performed on 0.5 mmol of 1 (1.0 equiv.) scale, and TMSCF<sub>3</sub> was added in two portions every 6 h; 1.5 equivalents of TMSC<sub>6</sub>F<sub>5</sub> was used; the molar ratio of TMSC<sub>6</sub>F<sub>5</sub>: CuCl: KF: TMSCF<sub>3</sub> = 1:4:3:1.9.  $^b$  1.6 equivalent of TMSC<sub>6</sub>F<sub>5</sub> was used. <sup>c</sup> 1.8 equivalent of TMSC<sub>6</sub>F<sub>5</sub> was used.

of CuC<sub>2</sub>F<sub>5</sub>, we envisaged that adding TMSCF<sub>3</sub> in batches to decrease the concentration of CuCF<sub>3</sub> might be helpful. After some brief optimizations and decreasing the amount of TMSCF<sub>3</sub> to 1.9 equivalents (entries 9-11), C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu was formed in 92% yield, together with 2% of C<sub>6</sub>F<sub>5</sub>Cu and 4% of CuCF<sub>3</sub> being formed (entry 11). Prolonging the reaction time to 36 hours did not have any beneficial effect (entry 12). Finally, when the reaction was conducted at room temperature for 28 hours, then stirred at 60 °C for 2 hours, no C<sub>6</sub>F<sub>5</sub>Cu and little amounts of CuCF<sub>3</sub> (1%) and CuC<sub>2</sub>F<sub>5</sub> (2%) could be detected, with C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu being formed in 89% yield (entry 13).

With the optimized conditions (Table 1, entry 13) in hand, the reactivity of this TMSCF3-derived C6F5CF2CF2Cu towards aryl iodides was studied. A variety of structurally diverse (hetero)aryl and alkenyl iodides are all viable substrate, giving the desired tetrafluoroethylene-bridged products in moderate to good yields (Scheme 3). The electronic character of arvl iodides do not have obvious influence on the reaction efficiency, and both electron-deficient (2a-i) and electron-rich (2k-p, 2r-s) substrates were readily transformed to the desired products in good yields. Common functional groups such as nitro (2a-c, in ortho, meta and para positions), acetyl (2d), ester (2e), cyano (2f), sulfonamide (2h) and sulfone (2i) were compatible with the reaction conditions, and good yields of products were observed. Notably, because of the mildness of the reaction conditions, some sensitive functionalities including aldehyde (2g, 2ab-ac), alcohol (2m) and unprotected NH group (2u, 2ab), were also tolerated. Heterocycles, such as pyrazole (2p), coumarin (2q), carbazole (2r), benzothiophene (2s), quinoline (2t) and indole (2u) were competent under the reaction conditions, as demonstrated by the formation of tetrafluoroethylene-bridged products in high yields. Moreover, heteroaryl iodides, including iodopyridine (2w-x), iodoimidazole (2y), iodoisoxazole (2z), iodothiophene (2aa), iodopyrrole (2ab) and iodofuran (2ac), participated in this perfluorophenylethylation to afford corresponding products in moderate to good yields (54-84%). Iodoalkene 1ad also showed good reactivity towards C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu, furnishing the desired product 2ad in 88% yield. This protocol is also

Scheme 4 Gram-scale synthesis.

**Edge Article Chemical Science** 

Fig. 1 (a) The single crystal structure and (b) packing diagram of 2n.36

effective for the perfluorophenylethylation of relatively complex compounds and pharmaceutical intermediates 1ae and 1af, giving the corresponding products 2ae and 2af in 96% and 88% yields, respectively. The broad scope of this reaction underscores the great potential of its application in the synthesis of a raft of valuable -CF<sub>2</sub>CF<sub>2</sub>- bridged molecules.

The inherent value of our controllable double CF2-insertion strategy with TMSCF3 for the introduction of tetrafluoroethylene bridge is further demonstrated by its applicability to gram-scale synthesis. For example, when iodoisoxazole 1z was scaled up to 5 mmol (1.12 g), the desired product 2z was obtained in 83% yield (1.50 g). Analogously, pharmaceutical intermediates 1ae and 1af were also successfully scaled up to 5 mmol, with the yields comparable to that on 0.5 mmol scale (Scheme 4).

It is worthwhile to note that the tetrafluoroethylene-bridged product 2n possesses interesting conformation and intermolecular interaction. As shown in Fig. 1,36 the single crystal structure of product 2n shows that the dihedral angle of C10-C11-C12-C13 is 174.1°, and two aromatic (the naphthalenyl and pentafluorophenyl) rings in 2n are almost parallel to each other (see Fig. 1a, also see ESI†). The packing diagram shows there are extensive intermolecular  $\pi$ - $\pi$  stackings between naphthalenyl and pentafluorophenyl rings of 2n (Fig. 1b), which might find useful applications in crystal engineering and materials science.

#### Conclusions

In conclusion, a controllable double CF<sub>2</sub>-insertion into C<sub>6</sub>F<sub>5</sub>Cu was realized using TMSCF<sub>3</sub> as the difluoromethylene source. The resulting C<sub>6</sub>F<sub>5</sub>CF<sub>2</sub>CF<sub>2</sub>Cu species showed high reactivity towards various (hetero)aryl iodides and alkenyl iodides,

providing an easy access to a variety of -CF2CF2- bridged molecules. Compared with previous methods for the construction of -CF<sub>2</sub>CF<sub>2</sub>- unit, this approach owns several merits such as utilizing commercially available and environmentally benign reagents as the CF2 source, easy to handle, broad substrate scope and mild conditions. This double CF2-insertion strategy represents the second generation of fluorocarbon homologation reactions via difluoromethylene insertion using TMSCF3 (the first generation is single CF<sub>2</sub>-insertion into CuCF<sub>3</sub>). Further efforts to seek after novel CF2-insertion reactions using TMSCF3 are currently underway in our laboratory.

#### Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

This work was supported by the National Basic Research Program of China (No. 2015CB931900, 2016YFB0101200), the National Natural Science Foundation of China (No. 21632009, 21421002), the Key Programs of the Chinese Academy of Sciences (No. KGZD-EW-T08), the Key Research Program of Frontier Sciences of CAS (No. QYZDJ-SSW-SLH049), and Shanghai Science and Technology Program (No. 18JC1410601).

#### Notes and references

- 1 K. Uneyama, Organofluorine Chemistry, Blackwell, Oxford, 2006.
- 2 P. Kirsch, Modern Fluoroorganic Chemistry: Synthesis. Reactivity, Applications, Wiley-WCH, Weinheim, 2nd edn, 2013.

3 I. Ojima, Fluorine in Medicinal Chemistry and Chemical Biology, Wiley-Blackwell, Chichester, U.K., 2009.

**Chemical Science** 

- 4 R. Berger, G. Resnati, P. Metrangolo, E. Weber and J. Hulliger, *Chem. Soc. Rev.*, 2011, **40**, 3496–3508.
- 5 J. Zhu, C. Ni, B. Gao and J. Hu, *J. Fluorine Chem.*, 2015, 171, 139–147.
- 6 P. Kirsch and M. Bremer, ChemPhysChem, 2010, 11, 357-360.
- 7 P. Kirsch, F. Huber, M. Lenges and A. Taugerbeck, *J. Fluorine Chem.*, 2001, **112**, 69–72.
- 8 P. Kirsch, M. Bremer, F. Huber, H. Lannert, A. Ruhl, M. Lieb and T. Wallmichrath, *J. Am. Chem. Soc.*, 2001, **123**, 5414–5417.
- 9 Y. Chang, A. Tewari, A.-I. Adi and C. Bae, *Tetrahedron*, 2008, 64, 9837–9842.
- 10 R. P. Singh, U. Majumder and J. n. M. Shreeve, *J. Org. Chem.*, 2001, **66**, 6263–6267.
- 11 W. R. Hasek, W. C. Smith and V. A. Engelhardt, J. Am. Chem. Soc., 1960, 82, 543–551.
- 12 J. Gatenyo and S. Rozen, *J. Fluorine Chem.*, 2009, **130**, 332-335
- 13 C. York, G. K. S. Prakash and G. A. Olah, J. Org. Chem., 1994, 59, 6493–6494.
- 14 M. Zupan and A. Pollak, J. Org. Chem., 1974, 39, 2646-2647.
- 15 H. Shirataki, T. Ono, M. Ohashi and S. Ogoshi, *Org. Lett.*, 2019, **21**, 851–856.
- 16 T. Kawashima, M. Ohashi and S. Ogoshi, J. Am. Chem. Soc., 2018, 140, 17423–17427.
- 17 H. Shirataki, M. Ohashi and S. Ogoshi, Eur. J. Org. Chem., 2019, 1883–1887.
- 18 T. Kawashima, M. Ohashi and S. Ogoshi, *J. Am. Chem. Soc.*, 2017, **139**, 17795–17798.
- 19 M. Ohashi, N. Ishida, K. Ando, Y. Hashimoto, A. Shigaki, K. Kikushima and S. Ogoshi, *Chem. –Eur. J.*, 2018, **24**, 9794–9798.
- 20 M. Ohashi, T. Adachi, N. Ishida, K. Kikushima and S. Ogoshi, *Angew. Chem., Int. Ed.*, 2017, 56, 11911–11915.

- 21 M. Ohashi, H. Shirataki, K. Kikushima and S. Ogoshi, *J. Am. Chem. Soc.*, 2015, **137**, 6496–6499.
- 22 H. Saijo, M. Ohashi and S. Ogoshi, *J. Am. Chem. Soc.*, 2014, 136, 15158–15161.
- 23 L. Li, C. Ni, Q. Xie, M. Hu, F. Wang and J. Hu, Angew. Chem., Int. Ed., 2017, 56, 9971–9975.
- 24 Z.-Y. Yang, D. M. Wiemers and D. J. Burton, *J. Am. Chem. Soc.*, 1992, **114**, 4402–4403.
- 25 Z.-Y. Yang and D. J. Burton, J. Fluorine Chem., 2000, 102, 89– 103.
- 26 X. Liu, C. Xu, M. Wang and Q. Liu, *Chem. Rev.*, 2015, 115, 683-730.
- 27 S. Roy, B. T. Gregg, G. W. Gribble, V.-D. Le and S. Roy, *Tetrahedron*, 2011, **67**, 2161–2195.
- 28 R. P. Singh and J. n. M. Shreeve, *Tetrahedron*, 2000, **56**, 7613-7632.
- 29 J.-A. Ma and D. Cahard, *J. Fluorine Chem.*, 2007, **128**, 975-
- 30 G. K. Prakash and A. K. Yudin, Chem. Rev., 1997, 97, 757-786.
- 31 F. Wang, T. Luo, J. Hu, Y. Wang, H. S. Krishnan, P. V. Jog, S. K. Ganesh, G. K. Prakash and G. A. Olah, *Angew. Chem.*, *Int. Ed.*, 2011, 50, 7153–7157.
- 32 G. M. Lee, D. J. Harrison, I. Korobkov and R. T. Baker, *Chem. Commun.*, 2014, **50**, 1128–1130.
- 33 L. Li, C. Ni, Q. Xie, M. Hu, F. Wang and J. Hu, *Angew. Chem., Int. Ed.*, 2017, **56**, 9971–9975.
- 34 Q. Xie, L. Li, Z. Zhu, R. Zhang, C. Ni and J. Hu, *Angew. Chem.*, *Int. Ed.*, 2018, 57, 13211–13215.
- 35 The chemical shifts of these fluoroalkylcopper/ fluoroarylcopper species were assigned as follows (in ppm):  $C_6F_5CF_2CF_2Cu$ , -101.1 (t, 2F), -106.6 (s, 2F), -139.4 (m, 2F), -153.1 (t, 1F), -163.9 (t, 2F);  $C_6F_5Cu$ , -111.0 (d, 2F), -163.3 (t, 1F), -164.3 (t, 2F);  $CuCF_3$ , -26.7 (s, 3F);  $CuC_2F_5$ , -84.0 (s, 3F), -112.4 (s, 2F).
- 36 CCDC 1957757† contains the supplementary crystallographic data for compound **2n**.